

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of Applicants:

M. Angelopoulos et al.

Serial No.:

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For: ATTENUATED EMBEDDED PHASE SHIFT PHOTOMASK BLANKS

Date: September 8, 2003

Group Art Unit:

Examiner:

Docket No.: YOR920010135US2

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT